

# An analytical method with numerical results to be used in the design of optical slab waveguides for optical communication system applications

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## ABSTRACT

This study develops an analytical method with numerical results for the design of optical slab waveguides for optical communication system applications. An optical slab waveguide structure made of silicon on silicon dioxide material is designed and analyzed. The effective index of the mode is studied against variations in the waveguide dimensions. Transmission and reflection coefficients are studied and compared to the wavelength and dimensions of the waveguide. Variations are sketched with the x-axis, in addition to the electric field intensity distribution and effective refractive index. Waveguide bending loss is also studied with waveguide thickness and length variations within three waveguide transmission windows of 850 nm, 1300nm, and 1550nm.

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## 1. INTRODUCTION

A uniform dielectric waveguide is the most basic structure in fiber and integrated optics. Therefore, the calculation of the modal characteristics of uniform dielectric waveguides is a fundamental research topic [1, 2]. Since so many important physical similarities exist between dielectric and metal waveguides, it seems that the well-established methods for analyzing metallic waveguides can be easily and directly applied to dielectric waveguides [3-5]. However, this is rarely the case. It may happen that a method that is highly successful for metallic waveguides may become unsuitable, if not useless, for the dielectric counterparts. This is particularly true for analytical methods. For example, the method of separation of variables applies remarkably well to a rectangular metallic waveguide but fails for a rectangular dielectric rod because of the presence of interfaces between different dielectrics [2, 6].

The analytical results are far more complicated than those for the circular metallic tube, even for the familiar circular step-index fiber [1, 7, 8]. Dielectric waveguides are, indeed, much more difficult to analyze analytically. Moreover, optical waveguide technology has advanced to a stage of high sophistication; therefore, scientists and engineers must study more complex and general waveguide structures for which analytical solutions simply do not exist. It is necessary to construct good numerical methods that can handle very general optical waveguides. In the meantime, the rapid growth of computer technology has also popularized the application of numerical methods [1, 4, 7-9].

To a large extent, the numerical methods used to analyze dielectric waveguides are basically those that have been widely applied to hollow metallic waveguides, for example, the finite element method and the finite difference method [1, 4, 7, 10, 11]. However, the existence of hybrid modes in a dielectric waveguide has complicated the formulation of these conventional methods significantly, and accurate modeling of the open region of the waveguide has further reduced their computational efficiency. Research efforts have been directed to either invent completely new numerical methods specifically for dielectric waveguides or modify existing methods to circumvent some or all of their disadvantages. The effective index method is one of these new methods, and the finite element method is the most extensively adapted method [2, 7, 9, 12].

In [1, 2, 7, 13], using a perturbation method, has derived an accurate explicit far from cutoff formula for TE modes of symmetric three-layer isotropic slab waveguides. Their formula is generalized to account for both TE and TM modes of isotropic and anisotropic waveguides. However, it is found that the accuracy of the formula for TM modes in the low-frequency range decreases significantly with increasing slab-cladding index ratio. A close to a cutoff formula is then derived to complement the far from the cutoff formula.

**2. MODEL DESCRIPTION AND RESEARCH METHOD**

An optical slab waveguide is constructed using a silicon material doped with germanium material with a refractive index of  $n_1$ . The available doping ratio of germanium is added to the silicon material up to 30% in order to upgrade the waveguide transmission performance. The optical slab waveguide configuration is rectangular and  $b$  is the length,  $\lambda$  is the waveguide wavelength, and  $t$  is the optical waveguide thickness. The surrounding regions along the optical slab waveguide are made of silicon dioxide material, which acts as an insulator that has a refractive index of  $n_2$ . The other regions consist of free space (air) with a refractive index of  $n_0$ . Optical slab waveguide as shown in Figure 1.

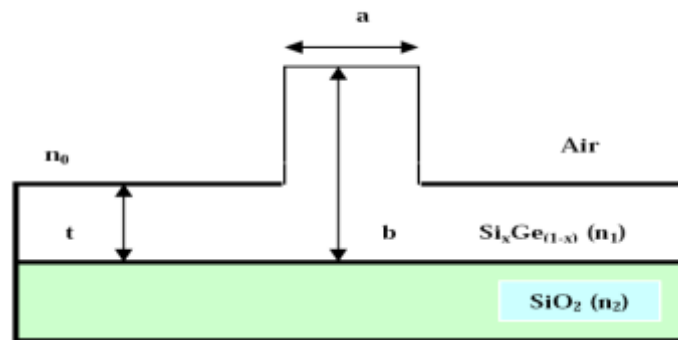


Figure 1. Optical slab waveguide structure made of silicon on silicon dioxide material

The relationship between the index of refraction for the core layer and the index of refraction for the cladding layer can be classified using Snell's law, if total internal reflection occurs [1, 2, 7-12]:

$$n_1 \sin \theta_1 = n_2 \sin \theta_2 \tag{1}$$

If total internal reflection occurs and  $\theta_2=90$  degrees, then the critical angle will be:

$$\theta_c = \sin^{-1} \left( \frac{n_2}{n_1} \right) \tag{2}$$

where the multiplication of the electric field and magnetic field can be expressed in terms of permittivity and permeability as [1, 2, 13-17]:

$$S = E \times H = \sqrt{\frac{\epsilon_m}{\mu_m}} E^2 \tag{3}$$

where the reflection coefficient ( $r$ ) for the transverse electric and transverse magnetic are given by [1, 7-9]:

$$r_{TE} = \frac{n_1 \cos(\theta_1) - \sqrt{n_2^2 - n_1^2 \sin^2(\theta_1)}}{n_1 \cos(\theta_1) + \sqrt{n_2^2 - n_1^2 \sin^2(\theta_1)}} \quad (4)$$

$$r_{TM} = \frac{n_2^2 \cos(\theta_1) - n_1 \sqrt{n_2^2 - n_1^2 \sin^2(\theta_1)}}{n_2^2 \cos(\theta_1) + n_1 \sqrt{n_2^2 - n_1^2 \sin^2(\theta_1)}} \quad (5)$$

where the transmission coefficient (T) can be given as a basic main function of reflected coefficient (r) as:

$$T = 1 - r \quad (6)$$

where the transverse magnetic mode via a slab optical waveguide analysis [1, 2, 16, 18-22]:

$$\frac{\sqrt{\sin^2(\theta_1) - \left(\frac{n_1}{n_2}\right)^2}}{\cos(\theta_1)} = \tan\left(\frac{k_0 n_1 \cos(\theta_1) - m\pi}{2}\right) \quad (7)$$

In addition, the wave number in the optical slab waveguide is given by:

$$k_o = \frac{2\pi}{\lambda_o} \quad (8)$$

where  $\lambda_o$  is the waveguide wavelength. Where the waveguide length is b and the waveguide width is a, where the ratio between waveguide width and waveguide length is expressed by [1, 2, 7-10]:

$$\frac{a}{b} \leq \left(\frac{q + 4\pi b}{4\pi b}\right)^{1+0.3\sqrt{\left(\frac{q + 4\pi b}{q + 4\pi rb}\right)^2 - 1}} \quad (9)$$

$$q = \frac{\gamma_0}{\sqrt{n_1^2 - n_0^2}} + \frac{\gamma_2}{\sqrt{n_1^2 - n_2^2}} \quad (10)$$

where the bending radius of the optical slab waveguide can be expressed for the bend loss coefficient factor as [1, 2, 18, 23-25]:

$$\alpha_{bend} = C_1 e^{-C_2 R} \quad (11)$$

where the basic constants  $C_1$ ,  $C_2$ , and R is the bending radius of the slab waveguide are calculated by [1, 2, 4, 19]:

$$C_1 = \frac{\lambda_0 \cos^2\left(k_{xg} \frac{w}{2}\right) e^{k_{xs} w}}{w^2 k_{xs} n_{eff} \left(\frac{w}{2} + \frac{1}{2k_{xg}} \sin(wk_{xg}) + \frac{1}{k_{xs}} \cos^2\left(k_{xg} \frac{w}{2}\right)\right)} \quad (12)$$

$$C_2 = 2k_{xs} \left(\frac{\lambda_0 \beta}{2\pi n_{eff}} - 1\right) \quad (13)$$

Where  $\beta$  is the propagation constant,  $n_{\text{effc}}$  is the effective cladding refractive index, and  $k_{xs}$  is the decay or delay coefficient, and where the coupling coefficient for the different modes in the optical slab waveguide can be estimated by [2, 7, 9, 20, 21]:

$$\kappa = \frac{2k_{xc}^2 k_{xs} e^{-k_{xs}s}}{\beta w (k_{xs}^2 + k_{xc}^2)} \tag{14}$$

where the propagation constant  $\beta$  can be estimated by [1, 2, 7-12, 26-28]:

$$\beta = \beta_r - i \frac{\alpha_{\text{loss}}}{2} \tag{15}$$

where  $\alpha_{\text{loss}}$  is the loss coefficient and  $\beta_r$  is the reflection propagation constant, and where the core refractive index is given by the following equation [1, 2, 4, 7-10]:

$$n_1 = \sqrt{\frac{A_1 - B_1 \lambda}{C_1^2 - \lambda^2}} \tag{16}$$

where the constants are  $A_1=0.0675x$ ,  $B_1=2+0.012 x$ , and  $C_1=1.32 x+0.54$ . Moreover,  $x$  is the germanium dopant ratio that is added to the silicon fabrication material.

### 3. PERFORMANCE ANALYSIS WITH DISCUSSIONS

The effective index method was originally constructed to handle rectangular dielectric structures that are encountered in millimeter-wave transmission and integrated optics. The method aims to replace the approximate rectangular structure by two planar waveguides. This approach facilitates computation and provides an intuitive understanding of the modal properties of the waveguide. In fact, it is the simplest and most efficient method available for analyzing general rectangular dielectric waveguides. Table 1 lists the operating parameters for the slab rectangular waveguide.

Table 1. Parameters used in the rectangular slab waveguide

Parameters	Value/unit
Waveguide thickness, $t$	10 nm-30 nm
Waveguide length, $b$	0.2 $\mu\text{m}$ -1.6 $\mu\text{m}$
Waveguide width, $a$	0.1 $\mu\text{m}$ -0.3 $\mu\text{m}$
Waveguide wavelength	850 nm-1650 nm
Ge dopant ratio, $x$	2 %-30 %

Figure 2 clarifies the mode effective index variations with the waveguide length and thickness at an operating transmission wavelength of 850nm. As the waveguide thickness increases, the mode effective index increases. But as the waveguide length increases, mode effective index decreases. With a waveguide thickness of 30nm and a waveguide length of 0.2 $\mu\text{m}$ , the mode effective index is 1.521. With a waveguide thickness of 30nm and a waveguide length of 0.8 $\mu\text{m}$ , the mode effective index is 1.155. However, with a waveguide thickness of 30nm and waveguide length of 1.6 $\mu\text{m}$ , the mode effective index is 0.853.

Figure 3 indicates the mode effective index variations with the waveguide length and thickness with an operating transmission wavelength of 1300nm. As the waveguide thickness increases, mode effective index increases. However, as the waveguide length increases, the mode effective index decreases. With a waveguide thickness of 30nm and a waveguide length of 0.2 $\mu\text{m}$ , the mode effective index is 1.62. With a waveguide thickness of 30nm and a waveguide length of 0.8 $\mu\text{m}$ , the mode effective index is 1.332. However, with a waveguide thickness of 30nm and waveguide length of 1.6 $\mu\text{m}$ , the mode effective index is 0.889. Figure 4 shows the mode effective index variations with waveguide length and thickness at an operating transmission wavelength of 1550nm. As the waveguide thickness increases, the mode effective index increases. However, as the waveguide length increases, the mode effective index decreases. With a waveguide thickness of 30nm and a waveguide length of 0.2 $\mu\text{m}$ , the mode effective index is 1.702. With a waveguide thickness of 30nm and a waveguide length of 0.8 $\mu\text{m}$ , the mode effective index is 1.456. However, with a waveguide thickness of 30nm and a waveguide length of 1.6 $\mu\text{m}$ , the mode effective index is 0.976.

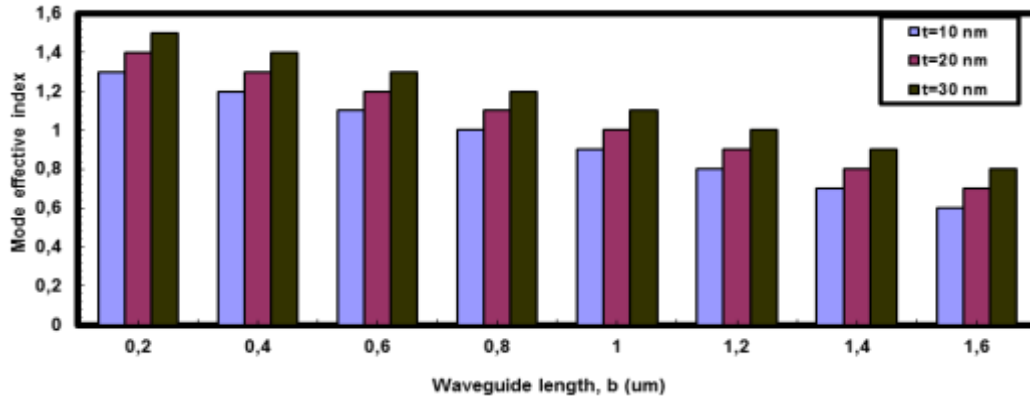


Figure 2. Mode effective index variations versus waveguide length and thickness at an operating wavelength of 850nm

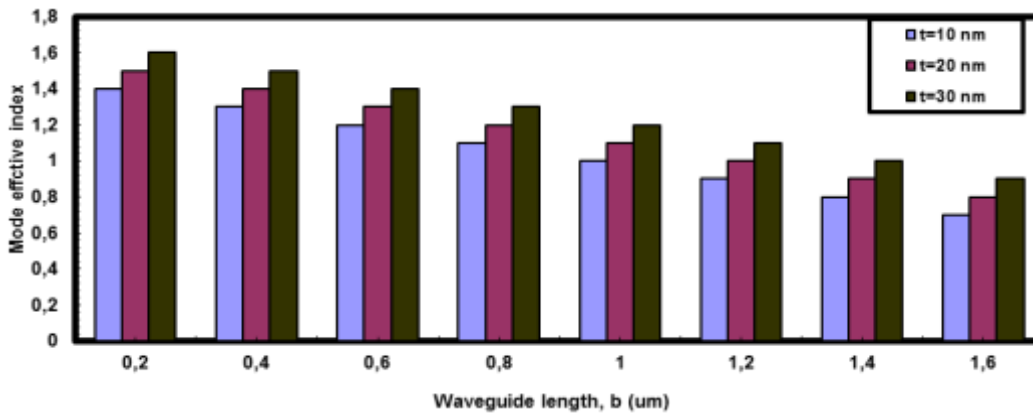


Figure 3. Mode effective index variations versus waveguide length and thickness at an operating wavelength of 1300nm

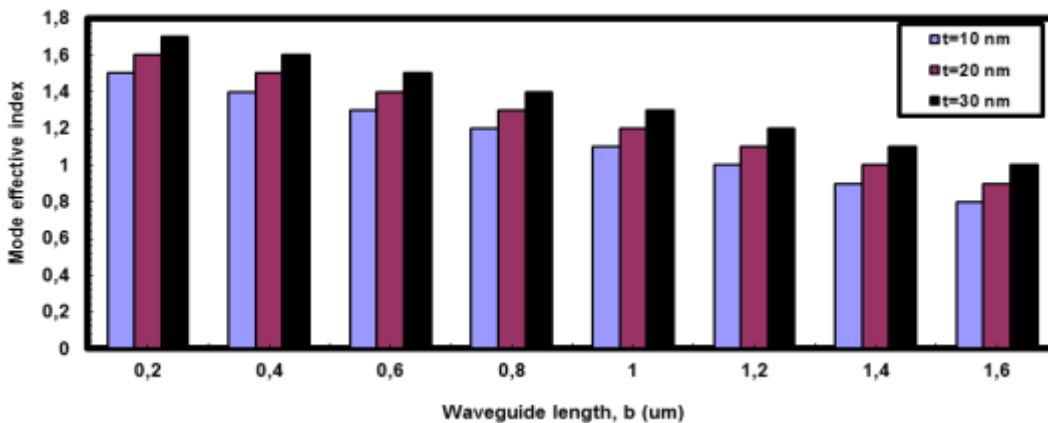


Figure 4. Mode effective index variations versus waveguide length and thickness at an operating wavelength of 1550nm

Figure 5 shows the transmission coefficient variations with waveguide wavelength and thickness variations. As the waveguide wavelength and width increase, the waveguide light transmission coefficient also increases. With a waveguide width value of 0.3μm and a waveguide wavelength value of 850nm, the

waveguide light transmission coefficient is 0.7795. With a waveguide width value of  $0.3\mu\text{m}$  and a waveguide wavelength value of  $1300\text{nm}$ , the waveguide light transmission coefficient is 0.8865. Moreover, with a waveguide width value of  $0.3\mu\text{m}$  and a waveguide wavelength value of  $1550\text{nm}$ , the waveguide light transmission coefficient is 0.995.

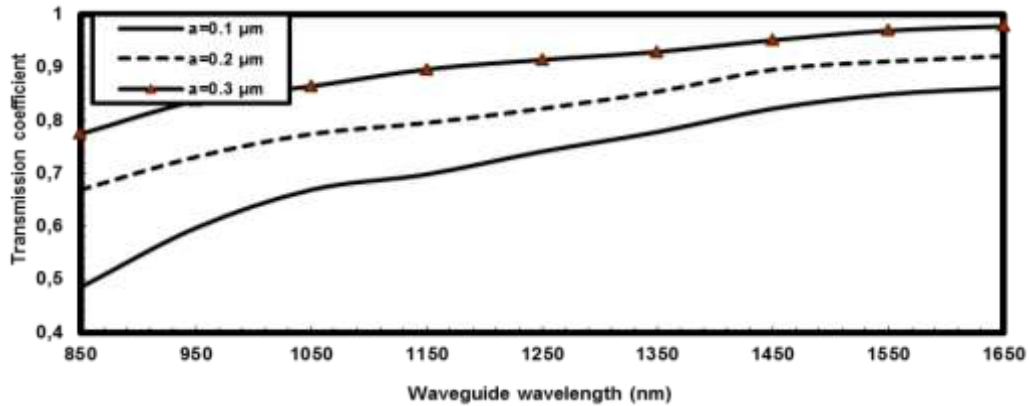


Figure 5. Transmission coefficient variations with waveguide wavelength and thickness variations

Figure 6 shows the reflection coefficient variations with waveguide wavelength and thickness variations. As the waveguide wavelength and width increases, the waveguide light reflection coefficient decreases. With a waveguide width value of  $0.3\mu\text{m}$  and a waveguide wavelength value of  $850\text{nm}$ , the waveguide light transmission coefficient is 0.3231. Moreover, with a waveguide width value of  $0.3\mu\text{m}$  and a waveguide wavelength value of  $1300\text{nm}$ , the waveguide light transmission coefficient is 0.1233. However, with a waveguide width value of  $0.3\mu\text{m}$  and a waveguide wavelength value of  $1550\text{nm}$ , the waveguide light reflection coefficient is 0.005.

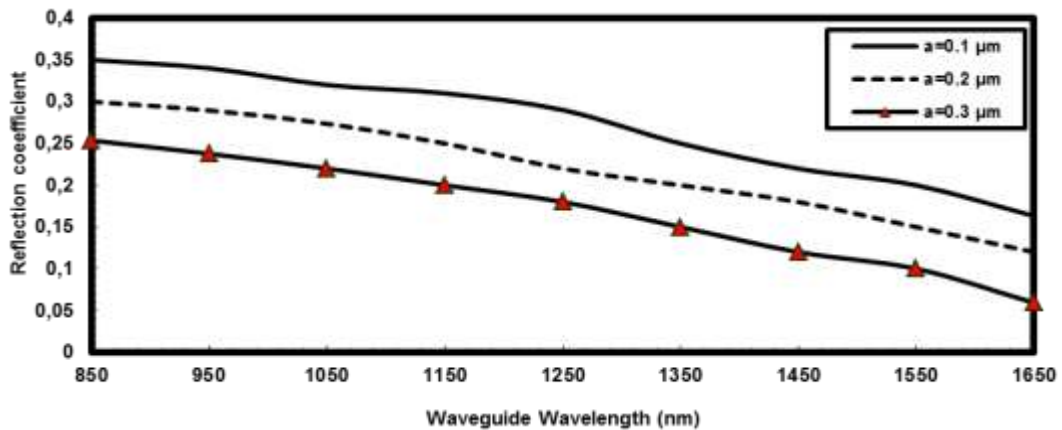


Figure 6. Reflection coefficient variations with waveguide wavelength and thickness variations

Figure 7 shows the electric field intensity and effective refractive index with x-axis distribution. This figure shows that the electric field intensity has reached a value of 0.8 and an effective refractive index value of 1.6. Figure 8 shows the waveguide bending loss variations with waveguide length and thickness at an operating wavelength of  $1550\text{nm}$ . With a waveguide thickness value of  $10\text{nm}$  and a waveguide length value of  $0.2\mu\text{m}$ , the waveguide bending loss is  $0.022 \times 10^{-4} \text{ dB}/\mu\text{m}$ . With a waveguide thickness value of  $10\text{nm}$  and a waveguide length value of  $0.8\mu\text{m}$ , the waveguide bending loss is  $0.085 \times 10^{-4} \text{ dB}/\mu\text{m}$ . However, with a waveguide thickness value of  $10\text{nm}$  and a waveguide length value of  $1.6\mu\text{m}$ , the waveguide bending loss value is  $0.136 \times 10^{-4} \text{ dB}/\mu\text{m}$ .

Figure 9 shows the waveguide bending loss variations with waveguide length and thickness at an operating wavelength of 1300nm. With a waveguide thickness value of 10nm and a waveguide length value of 0.2μm, the waveguide bending loss is  $0.041 \times 10^{-4}$  dB/μm. Moreover, with a waveguide thickness value of 10nm and a waveguide length value of 0.8μm, the waveguide bending loss is  $0.065 \times 10^{-4}$  dB/μm. However, with a waveguide thickness value of 10nm and a waveguide length value of 1.6μm, the waveguide bending loss value is  $0.135 \times 10^{-4}$  dB/μm. Figure 10 indicates the waveguide bending loss variations with a waveguide length and thickness at an operating wavelength of 850nm. With a waveguide thickness value of 10nm and a waveguide length value of 0.2μm, the waveguide bending loss value is  $0.062 \times 10^{-4}$  dB/μm. Mover, with a waveguide thickness value of 10nm and a waveguide length value of 0.8μm, the waveguide bending loss value is  $0.094 \times 10^{-4}$  dB/μm. Therefore, with a waveguide thickness value of 10nm and a waveguide length value of 1.6μm, the waveguide bending loss is  $0.142 \times 10^{-4}$  dB/μm.

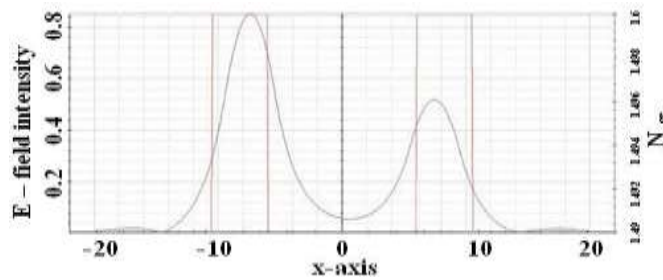


Figure 7. Electric field intensity and effective refractive index with x-axis distribution

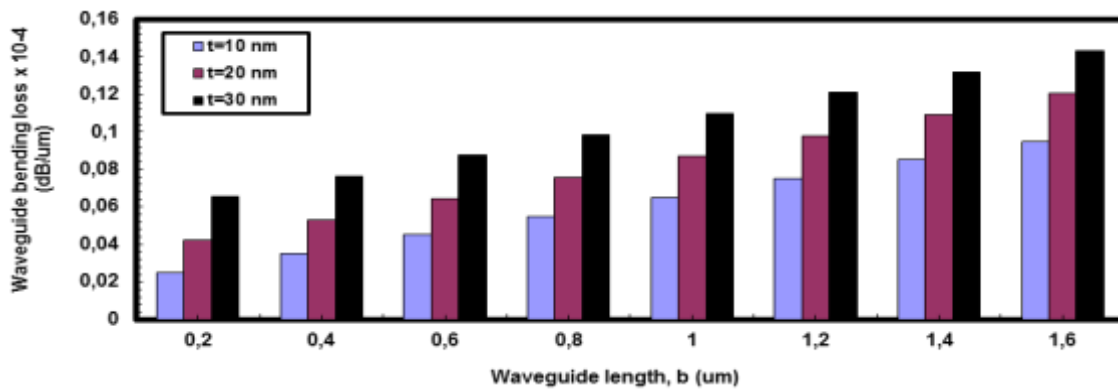


Figure 8. Waveguide bending loss variations with waveguide length and thickness at an operating wavelength of 1550nm

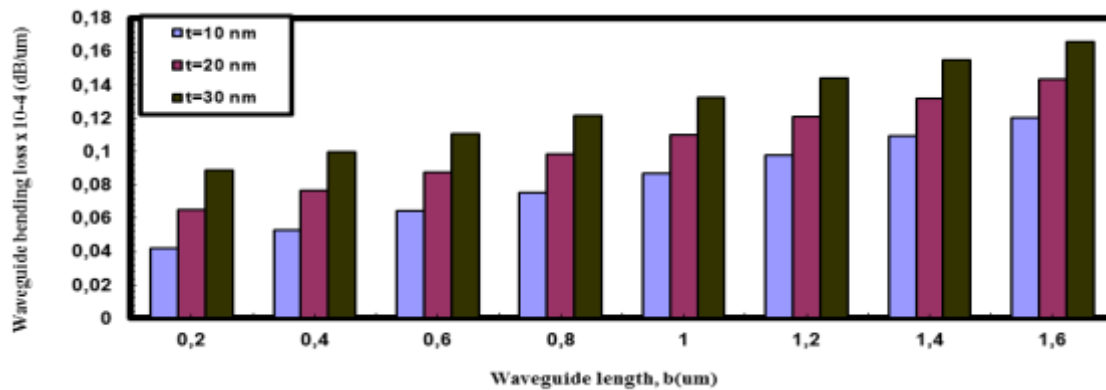


Figure 9. Waveguide bending loss variations with waveguide length and thickness at an operating wavelength of 1300nm

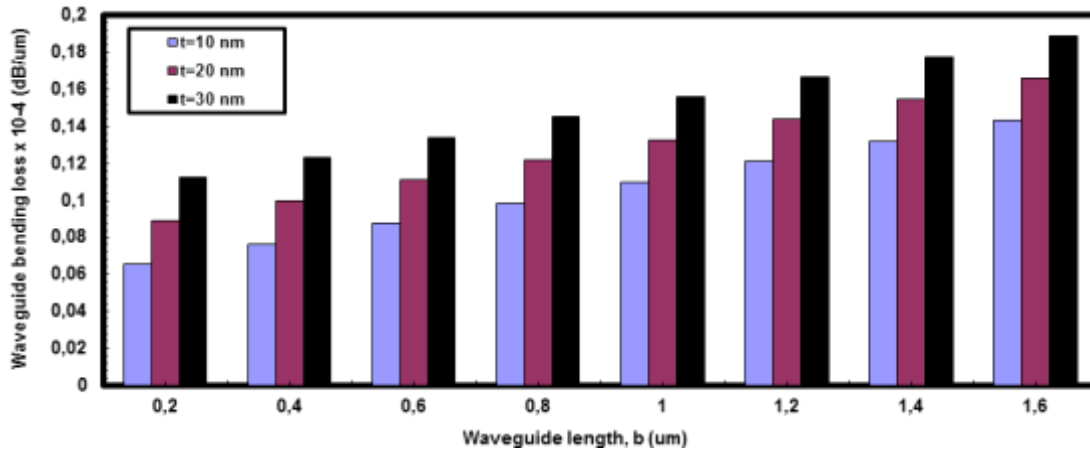


Figure 10. Waveguide bending loss variations with waveguide length and thickness at an operating wavelength of 850nm

Figure 11 shows the transmission and reflection coefficients versus the germanium dopant ratio at an operating wavelength of 1550nm. As the germanium dopant ratio increases, the transmission coefficient increases and the reflection coefficient decreases. Moreover, with a dopant ratio of 2%, the average transmission coefficient reaches 0.55 while the average reflection coefficient reaches 0.45. With a dopant ratio of 16%, the average transmission coefficient reaches 0.85 and the average reflection coefficient reaches 0.15. Finally, with a dopant ratio of 30%, the average transmission coefficient reaches 0.95 and the average reflection coefficient reaches 0.05.

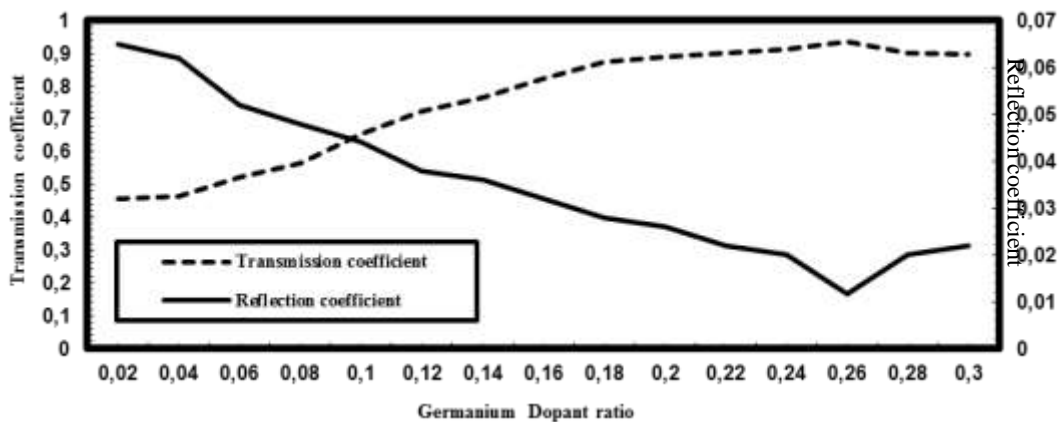


Figure 11. Transmission and reflection coefficients versus the germanium dopant ratio at an operating wavelength of 1550nm

#### 4. CONCLUSION

The design of the optical slab waveguide is designed and analyzed within three optical transmission windows of 850nm, 1300nm, and 1550nm. The waveguide bending loss can be optimized at a waveguide length of 0.2μm and a waveguide thickness of 10nm. Therefore, the optimum waveguide bending loss value is 0.022 x 10<sup>-4</sup> dB/μm. The electric field intensity distribution is 0.8 and the effective refractive index value is 1.6. In addition to the waveguide light transmission, the coefficient is 0.995 at a waveguide width of 0.3μm and a waveguide wavelength of 1550nm. The optimized waveguide light reflection coefficient is 0.005 at a waveguide width value of 0.3μm and a waveguide wavelength value of 1550nm. In the same way, the optimized mode effective index is reached at 0.976 with a waveguide thickness of 30nm and a waveguide length of 1.6μm.



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